

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Toshihiko OHASHI et al.

Application No.: 10/541,776

Confirmation No.: 1474

Filed: July 8, 2005

Art Unit: 1771

For: SILICA-CONTAINING LAMINATED
STRUCTURE, AND COATING
COMPOSITION FOR USE IN FORMING A
POROUS SILICA LAYER

Examiner: V. S. Chang

AMENDMENT AFTER FINAL ACTION UNDER 37 C.F.R. 1.116

MS AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated February 22, 2007, finally rejecting claims 1-3, 5, 14 and 15, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.